

Supporting Information for
**Theoretical prediction of efficient Cu-based dual-atom alloy catalysts for
electrocatalytic nitrate reduction to ammonia via high-throughput first-principles
calculations**

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Table S1. The zero-point energy corrections (ΔE_{ZPE}) and entropic contributions ($T\Delta S$) (at 298.15 K) to the free energies of the key intermediates

Species	E_{ZPE} (eV)	TS (eV)
*NO ₃	0.40	0.27
*NO ₃ H	0.62	0.27
*NO ₂	0.27	0.18
*NO ₂ H	0.54	0.18
*OH+*NO ₂	0.62	0.27
2*OH+*NO	0.92	0.25
*OH+*NO	0.53	0.20
*OH+*NOH	0.82	0.23
*NO-end	0.18	0.13
*NO-side	0.17	0.11
*NOH	0.45	0.17
*HNO	0.48	0.12
*N	0.08	0.03
*NH	0.38	0.04
*NH ₂	0.68	0.09
*NH ₃	1.00	0.14
*HNOH	0.77	0.18
*OH+*NH	0.72	0.16
*OH+*NH ₂	1.06	0.15
*OH+*NH ₃	1.37	0.22
*OH	0.34	0.08
2*OH	0.69	0.19
*N ₂ O ₂	0.36	0.23
*N ₂ O ₂ H	0.70	0.23
*N ₂ O	0.26	0.21
*N ₂ OH	0.56	0.18
*N ₂	0.17	0.22

Table S2. The zero-point energy corrections (ΔE_{ZPE}) and entropic contributions ($T\Delta S$) (at 298.15 K) to the free energies of the relevant molecules.

Species	E_{ZPE} (eV)	TS (eV)
HNO ₃ (g)	0.70	0.83
HNO ₂ trans(g)	0.53	0.77
NO ₂ (g)	0.23	0.74
NO(g)	0.12	0.65
NH ₃ (g)	0.89	0.60
H ₂ (g)	0.27	0.40
H ₂ O(g)	0.56	0.67
N ₂ (g)	0.15	0.58
N ₂ O(g)	0.29	0.68

Table S3. The key parameters of the TM₂Cu systems: formation energy (E_{form}) and binding energy (E_b) of the TM₂Cu systems, average net charge (ΔQ) of the TM dimers, distance ($d_{\text{TM-TM}}$) between the embedded TM dimer, distance ($d_{\text{TM-Cu}}$) between the embedded TM atom and its bonded Cu atoms.

TM ₂ Cu	E_{form} (eV)	E_b (eV)	ΔQ (e)	$d_{\text{TM-TM}}$ (Å)	$d_{\text{TM-Cu}}$ (Å)				
Sc ₂ Cu	0.94	-11.61	-2.00	2.85	2.66	2.59	2.49	2.59	2.68
Ti ₂ Cu	0.07	-12.45	-1.51	2.44	2.58	2.59	2.59	2.60	2.58
V ₂ Cu	-0.64	-11.75	-0.79	1.81	2.53	2.71	2.83	2.71	2.53
Cr ₂ Cu	0.29	-8.87	-0.73	2.68	2.60	2.53	2.49	2.53	2.60
Mn ₂ Cu	-0.18	-9.14	-0.59	2.65	2.56	2.53	2.49	2.53	2.57
Fe ₂ Cu	-0.30	-11.12	-0.29	2.28	2.50	2.57	2.62	2.57	2.50
Co ₂ Cu	-0.50	-11.51	-0.08	2.31	2.49	2.55	2.60	2.55	2.49
Ni ₂ Cu	0.01	-11.65	0.09	2.52	2.52	2.52	2.52	2.52	2.52
Zn ₂ Cu	0.10	-5.66	-0.18	2.59	2.55	2.52	2.51	2.53	2.55
Y ₂ Cu	1.35	-11.48	-1.29	3.12	2.84	2.71	2.57	2.71	2.85
Zr ₂ Cu	0.43	-14.90	-1.03	2.67	2.67	2.63	2.56	2.63	2.67
Nb ₂ Cu	-0.78	-15.59	-0.62	2.29	2.62	2.65	2.66	2.65	2.61
Mo ₂ Cu	-2.11	-13.73	-0.53	1.85	2.61	2.74	2.85	2.72	2.61
Ru ₂ Cu	-0.47	-14.97	0.09	2.36	2.58	2.57	2.60	2.55	2.56
Rh ₂ Cu	0.16	-14.25	0.30	2.55	2.58	2.54	2.53	2.53	2.57
Pd ₂ Cu	0.14	-11.63	0.33	2.63	2.60	2.54	2.51	2.54	2.60
Ag ₂ Cu	0.09	-8.39	0.11	2.65	2.65	2.58	2.53	2.58	2.65
Cd ₂ Cu	0.23	-4.59	-0.18	2.78	2.72	2.63	2.58	2.63	2.72
Hf ₂ Cu	0.56	-15.15	-2.38	2.74	2.63	2.59	2.51	2.59	2.65
Ta ₂ Cu	-0.46	-17.65	-1.20	2.42	2.60	2.62	2.60	2.62	2.60
W ₂ Cu	-1.35	-15.76	-0.55	2.26	2.58	2.62	2.66	2.62	2.58
Re ₂ Cu	-1.36	-14.67	-0.13	2.30	2.58	2.59	2.64	2.58	2.57
Os ₂ Cu	-0.81	-16.38	0.23	2.39	2.57	2.56	2.59	2.55	2.57
Ir ₂ Cu	0.01	-17.02	0.49	2.52	2.57	2.54	2.54	2.53	2.57
Pt ₂ Cu	0.19	-13.53	0.58	2.63	2.59	2.54	2.51	2.54	2.59
Au ₂ Cu	0.19	-10.51	0.43	2.68	2.64	2.56	2.52	2.56	2.63
Cu(111)	--	--	0.02	2.52	2.52	2.52	2.52	2.52	2.52

Table S4. The key parameters of NO_3^- adsorption on the TM_2Cu systems: distance between the O atoms in $^*\text{NO}_3$ and its bonded TM atoms, $d(\text{M-O}^*)$; adsorption free energy of NO_3^- , $\Delta G(^*\text{NO}_3)$; net charge of the $^*\text{NO}_3$, $\Delta Q(^*\text{NO}_3)$; net charge of TM dimer with adsorption of NO_3^- , $\Delta Q(\text{TM-}^*\text{NO}_3)$.

TM_2Cu	$d(\text{M-}^*\text{O})$ (Å)	$\Delta G(^*\text{NO}_3)$ (eV)	$\Delta Q(^*\text{NO}_3)$ (e)	$\Delta Q(\text{TM-}^*\text{NO}_3)$ (e)
V_2Cu	1.96, 1.96	-1.51	0.87	-0.54
Mn_2Cu	2.00, 1.99	-0.89	0.79	-0.44
Fe_2Cu	1.96, 1.96	-0.89	0.77	-0.50
Co_2Cu	1.96, 1.96	-0.64	0.74	-0.48
Nb_2Cu	2.07, 2.07	-1.07	0.70	-0.54
Mo_2Cu	2.08, 2.08	-1.60	0.87	-0.72
Ru_2Cu	2.10, 2.10	-0.64	0.67	-0.38
Ta_2Cu	2.04, 2.04	-2.06	1.14	-0.88
W_2Cu	2.01, 2.01	-2.21	1.05	-0.96
Re_2Cu	2.05, 2.05	-1.40	0.85	-0.82
Os_2Cu	2.11, 2.11	-0.60	0.69	-0.66
Cu111	2.03, 2.03	0.02	0.70	-0.10

Table S5. The key parameters of H atoms adsorption on the TM₂Cu systems: distance between the H atoms and TM dimers or Cu atoms, $\Delta d(\text{TM/Cu-H}^*)$; adsorption free energy of H atoms, $\Delta G(^*\text{H})$; net charge of the ${}^*\text{H}$, $\Delta Q(^*\text{H})$; net charge of TM dimer with adsorption of H, $\Delta Q(\text{TM-}{}^*\text{H})$.

TM ₂ Cu	$\Delta d(\text{TM/Cu-}{}^*\text{H})$ (Å)	$\Delta G(^*\text{H})$ (eV)	$\Delta Q(^*\text{H})$ (e)	$\Delta Q(\text{TM-}{}^*\text{H})$ (e)
V ₂ Cu	1.85, 1.86, 1.81	-0.43	0.53	-0.45
Mn ₂ Cu	1.81, 1.81, 1.77	-0.38	0.49	-0.28
Fe ₂ Cu	1.73, 1.73, 1.82	-0.44	0.41	-0.26
Co ₂ Cu	1.69, 1.68, 1.83	-0.47	0.33	-0.19
Nb ₂ Cu	1.90, 1.90, --	-0.59	0.44	-0.46
Mo ₂ Cu	1.92, 1.92, --	-0.12	0.46	-0.19
Ru ₂ Cu	1.82, 1.82, 1.90	-0.34	0.28	-0.18
Ta ₂ Cu	1.90, 1.90, --	-0.87	0.82	-0.80
W ₂ Cu	1.86, 1.86, --	-0.58	0.56	-0.59
Re ₂ Cu	1.90, 1.90, --	-0.40	0.37	-0.33
Os ₂ Cu	1.82, 1.82, --	-0.34	0.24	-0.22
Cu111	1.73, 1.73, 1.74	-0.18	0.27	-0.08

Table S6. The calculated values of U_L and corresponding potential-determining step (PDS) for eNO₃RR on TM₂Cu systems.

TM ₂ Cu	U_L (V)	Limiting step
V ₂ Cu	-0.73	*OH+*NH ₃ → *NH ₃
Mn ₂ Cu	-0.18	*NO → *NOH
Fe ₂ Cu	-0.30	*NO → *NOH
Co ₂ Cu	-0.28	*NO → *NOH
Nb ₂ Cu	-0.80	*OH+*NH ₃ → *NH ₃
Mo ₂ Cu	-0.76	*OH+*NH ₃ → *NH ₃
Ru ₂ Cu	-0.46	*NO → *NOH
Ta ₂ Cu	-1.48	*OH+*NH ₃ → *NH ₃
W ₂ Cu	-1.30	*OH+*NH ₃ → *NH ₃
Re ₂ Cu	-0.78	*OH+*NH ₃ → *NH ₃
Os ₂ Cu	-0.57	*NO → *NOH
Cu(111)	-0.38	*NO ₂ → *NO ₂ H

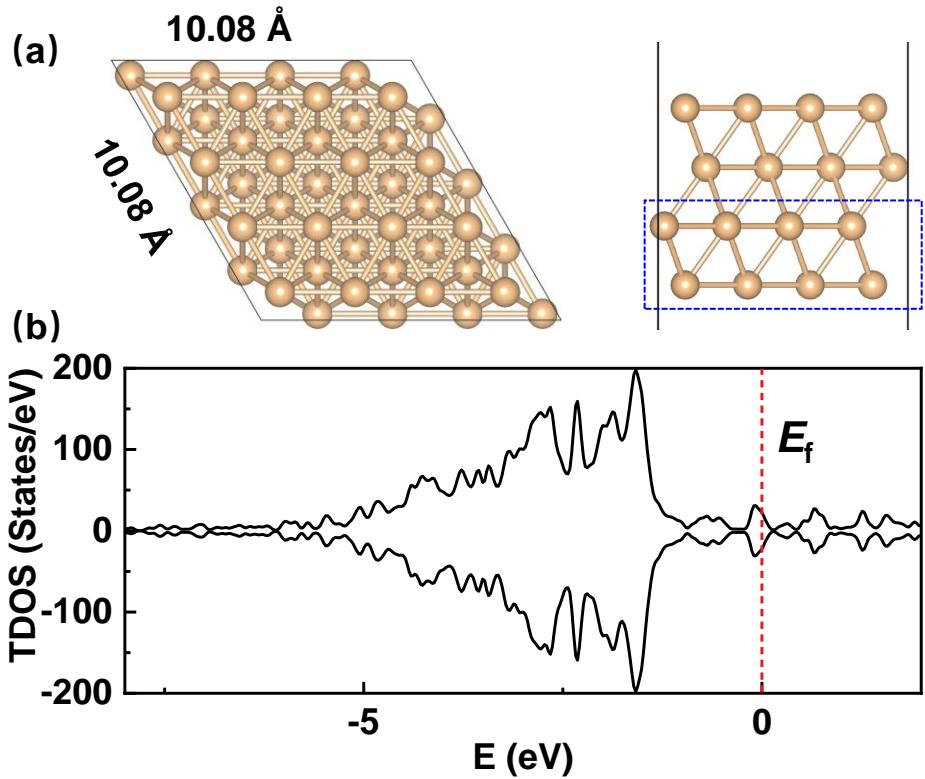


Fig. S1. (a) The atom configurations of $4 \times 4 \times 4$ supercell of the pristine Cu(111) slab, with the bottom two layers were fixed. (b) The total densities of states (TDOS) of the pristine Cu(111) slab.

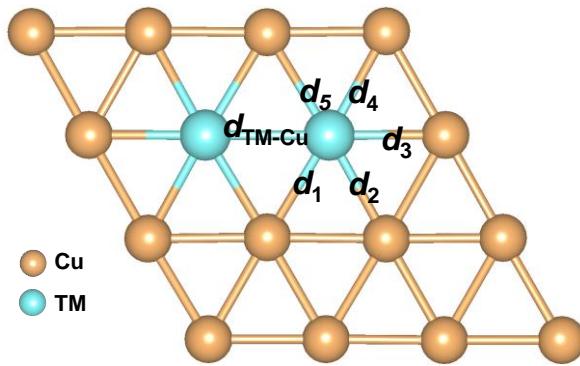


Fig. S2. The sites of TM bonding with Cu atoms, and d_1 , d_2 , d_3 , d_4 and d_5 corresponding to the values of $d_{\text{TM-Cu}}$ in Table S3, respectively.

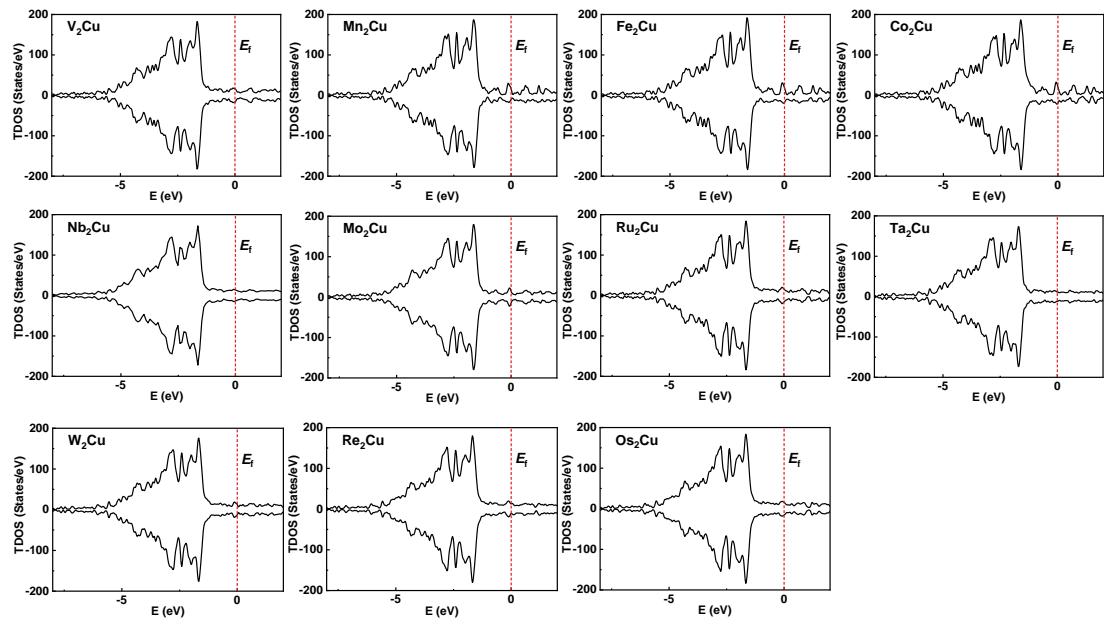


Fig. S3. The total densities of states (TDOS) of the screened TM_2Cu systems.

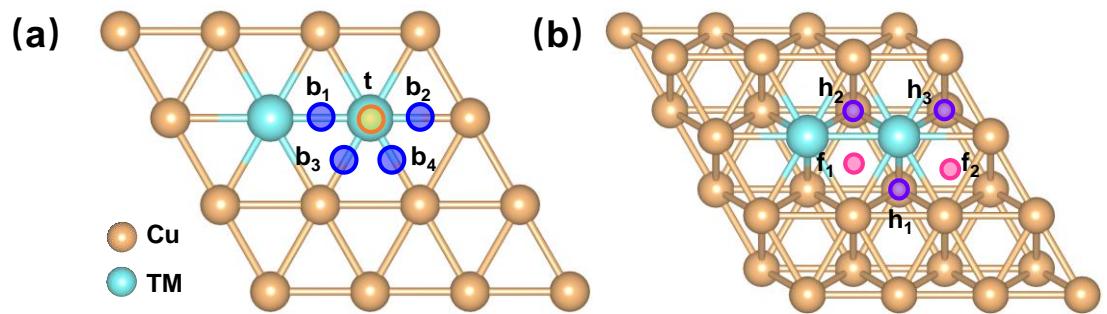


Fig. S4. (a) The considered adsorption sites of NO_3^- adsorbed on screened TM_2Cu catalysts, b_1 , b_2 , b_3 , b_4 , and t represent different bridge site and top site respectively. (b) The considered adsorption sites of H atom adsorbed on screened TM_2Cu catalysts, f_1 , f_2 and f_3 represent different fcc site, respectively, h_1 , h_2 and h_3 represent different hollow site, respectively.

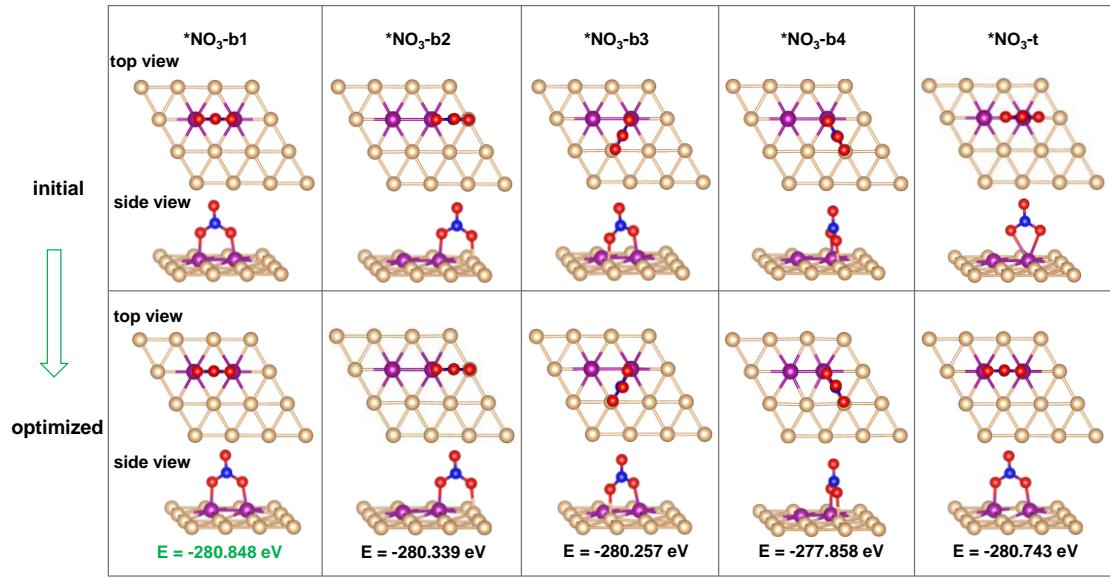


Fig. S5. The initial and optimized structures of several possible NO₃⁻ adsorption on Mn₂Cu catalyst.

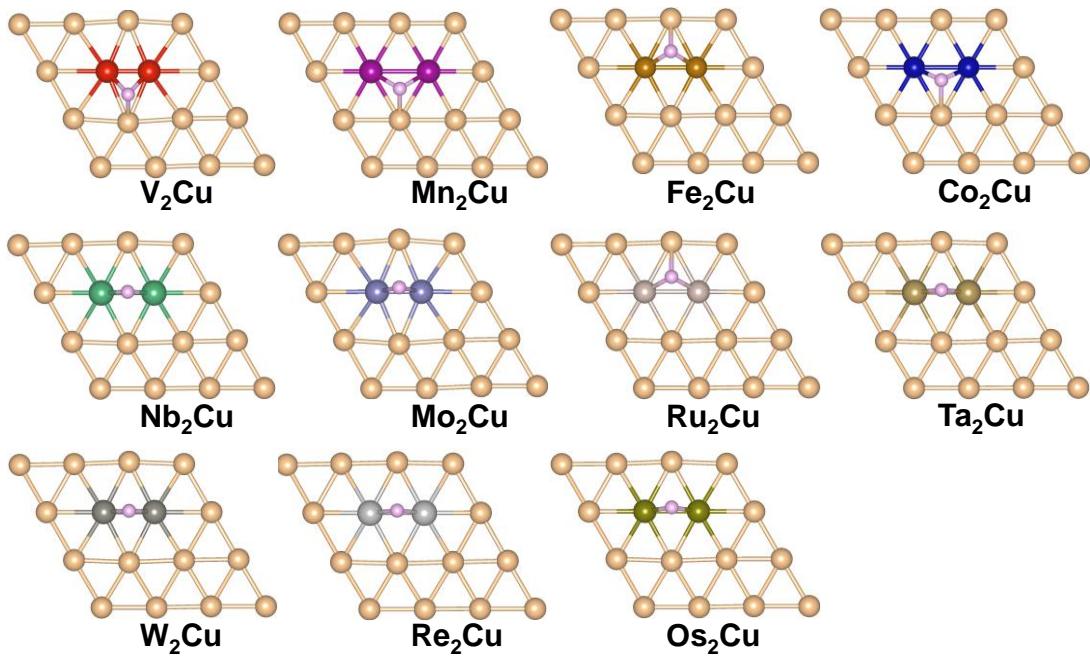


Fig. S6. The most stable adsorption configurations of H atoms on screened TM₂Cu catalysts.

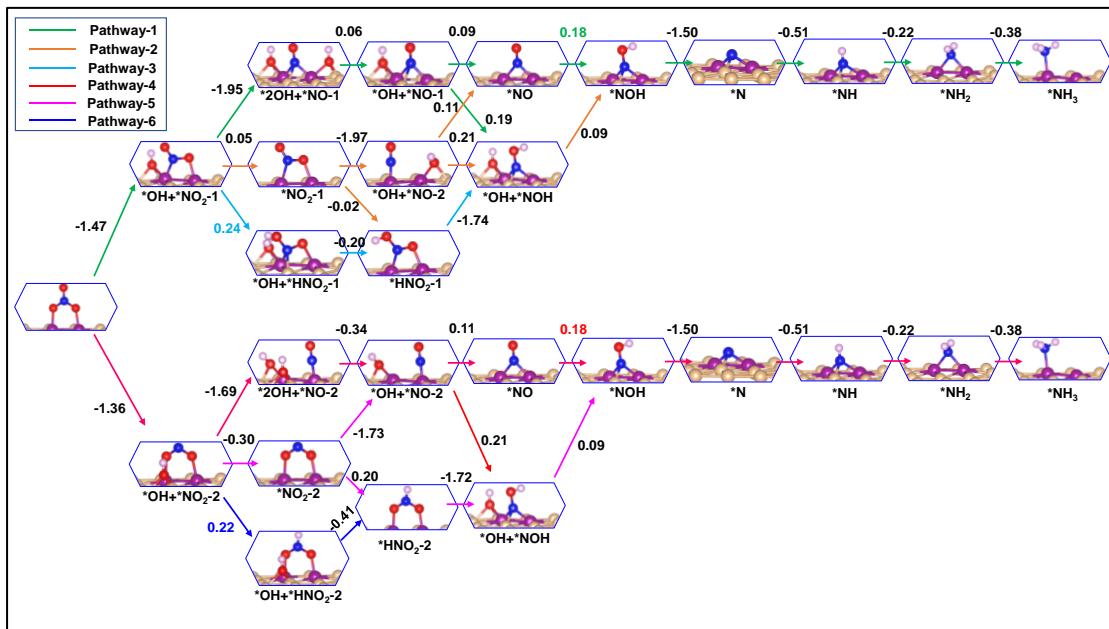


Fig. S7. The all possible reaction pathway on Mn_2Cu catalyst, which contain the optimized reaction intermediate structures and free energy changes in each elementary step. The green pathway contains the most stable configurations of the overall reaction, while the other color pathways along relatively unstable structures.

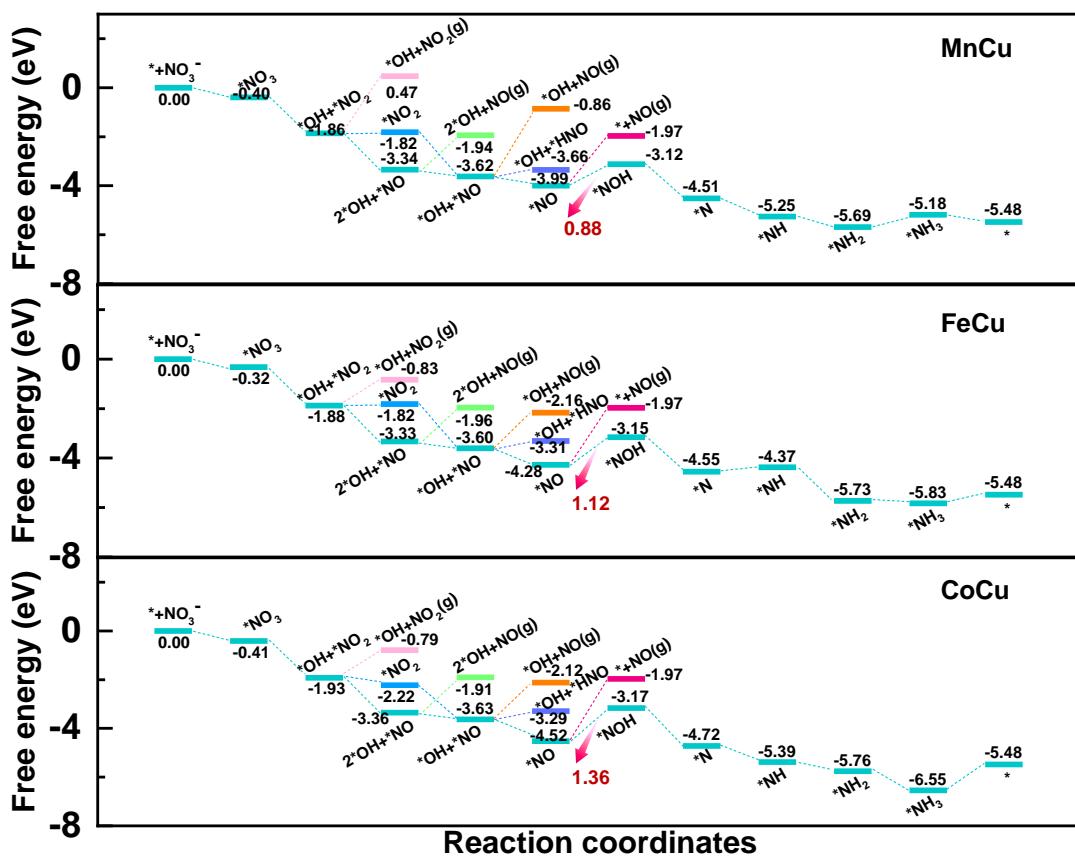


Fig. S8. Free energy diagram and the configurations of corresponding intermediates for the eNO₃RR on MnCu, FeCu, and CoCu SAA catalysts.

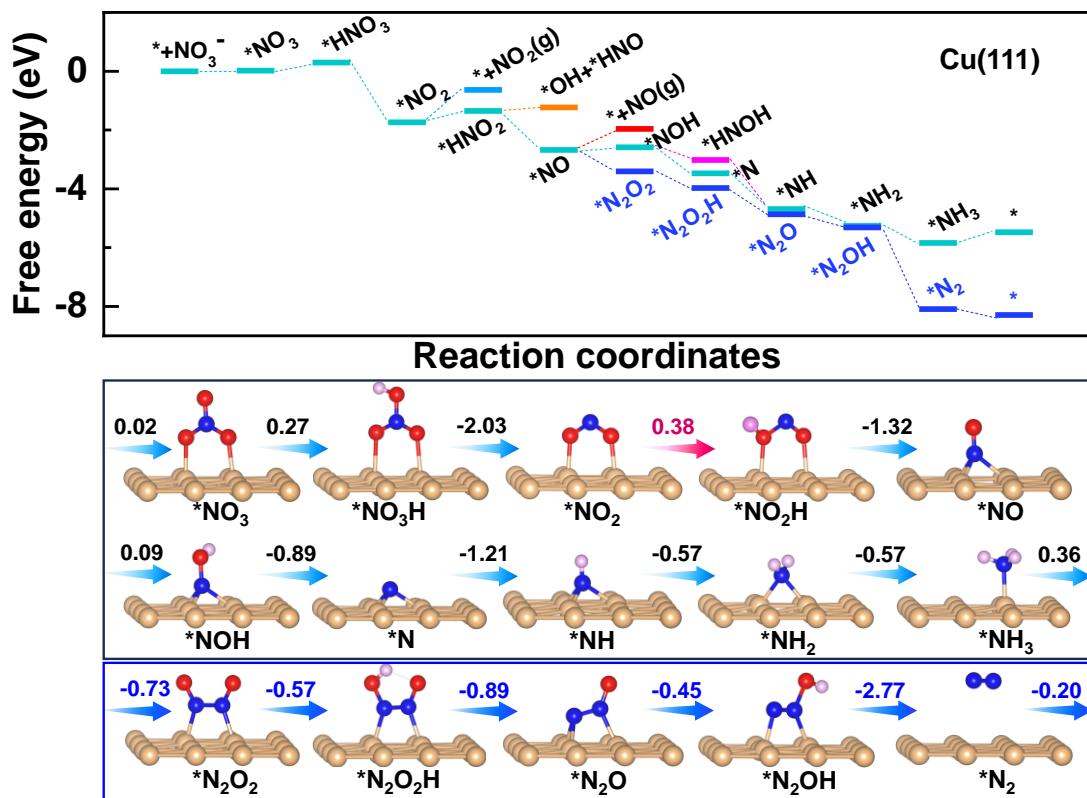


Fig. S9. Free energy diagram and the configurations of corresponding intermediates for the eNO₃RR on pristine Cu(111).

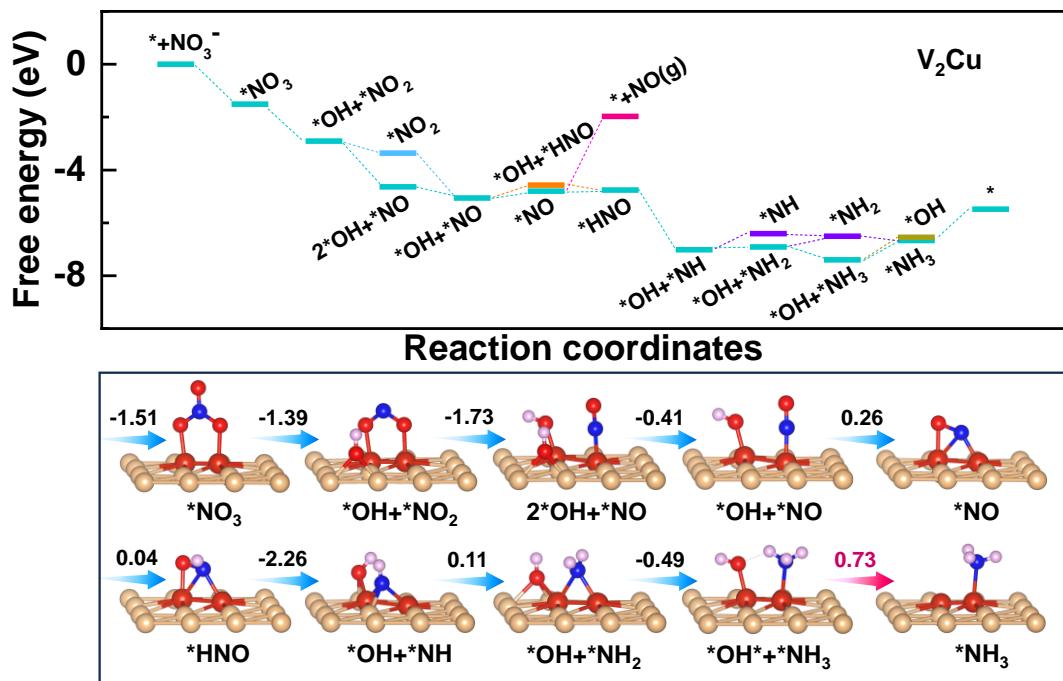


Fig. S10. Free energy diagram and the configurations of corresponding intermediates for the e NO_3 RR on V_2Cu .

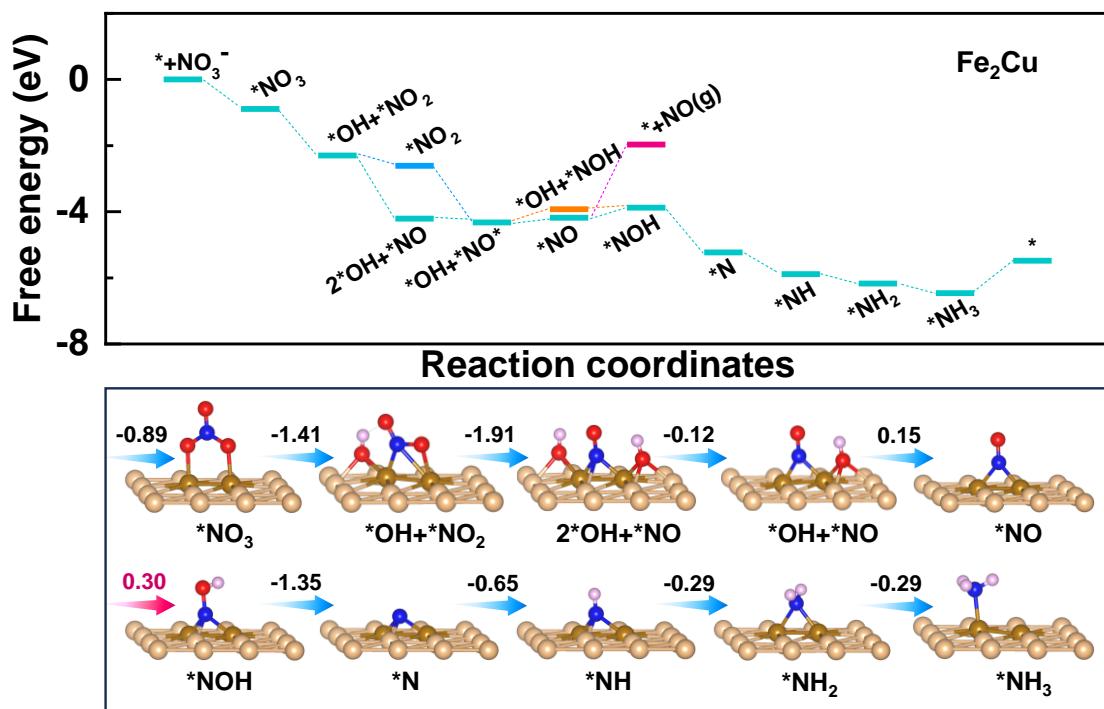


Fig. S11. Free energy diagram and the configurations of corresponding intermediates for the eNO₃RR on Fe₂Cu.

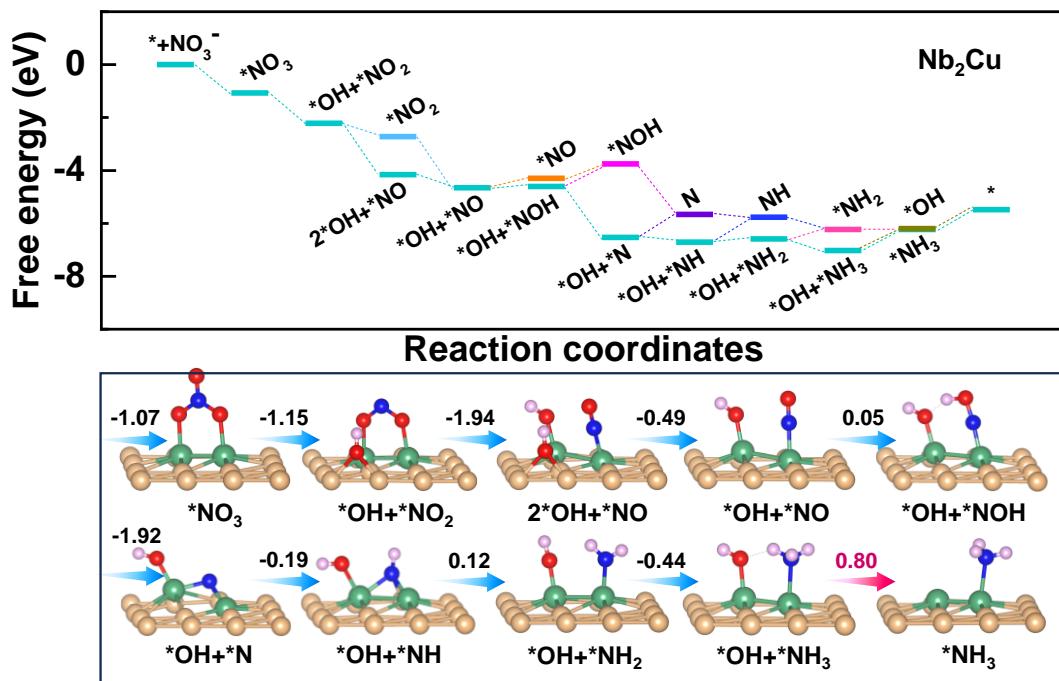


Fig. S12. Free energy diagram and the configurations of corresponding intermediates for the e NO_3 RR on Nb_2Cu .

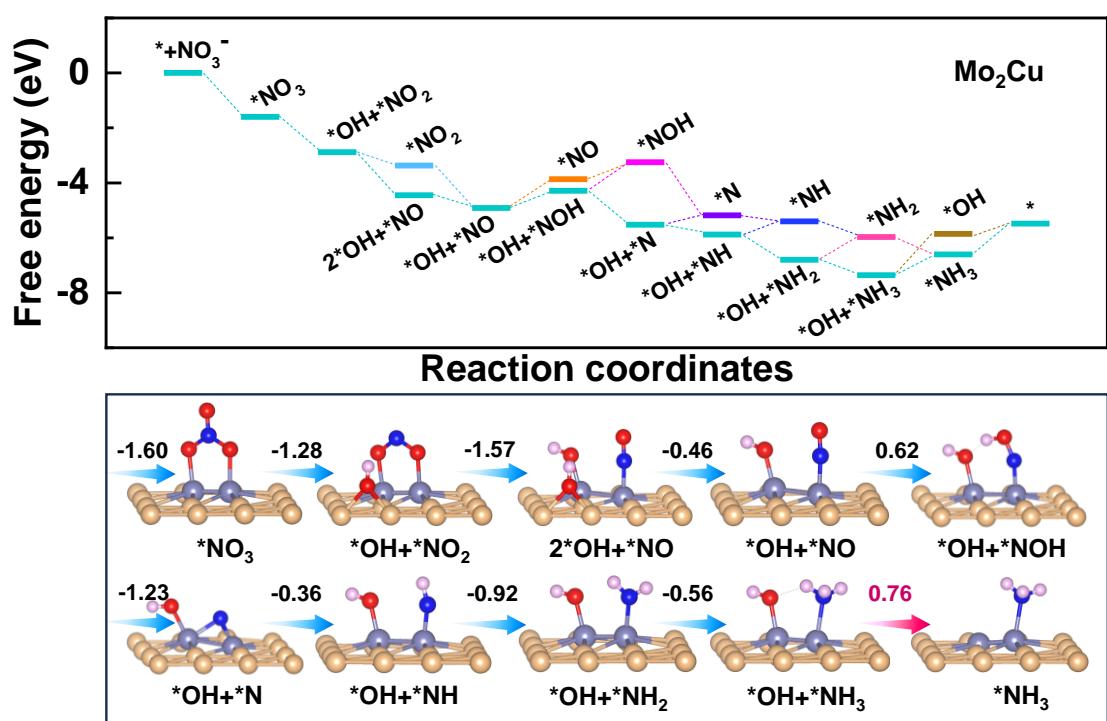


Fig. S13. Free energy diagram and the configurations of corresponding intermediates for the eNO_3RR on Mo_2Cu .

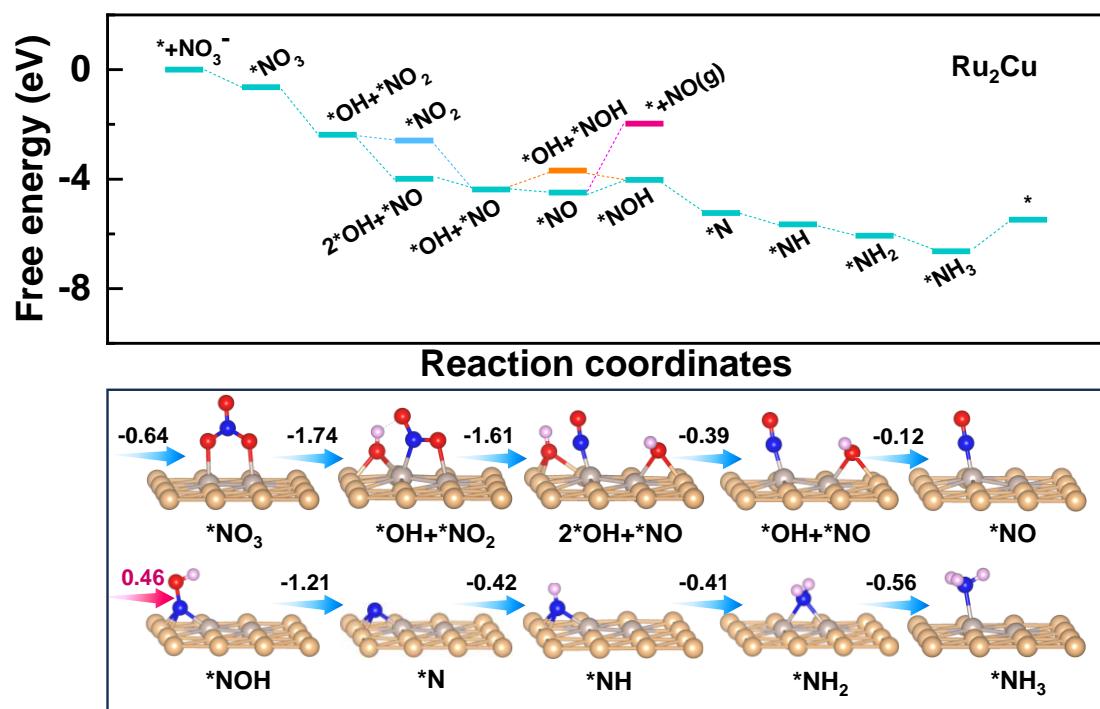


Fig. S14. Free energy diagram and the configurations of corresponding intermediates for the eNO_3RR on Ru_2Cu .

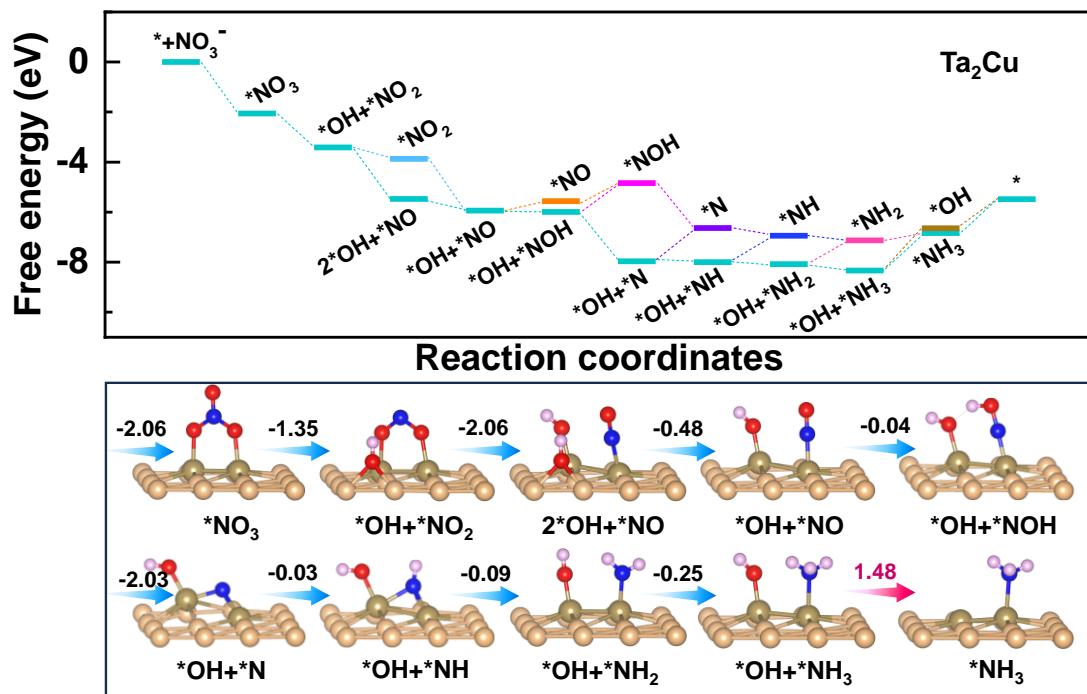


Fig. S15. Free energy diagram and the configurations of corresponding intermediates for the eNO_3RR on Ta_2Cu .

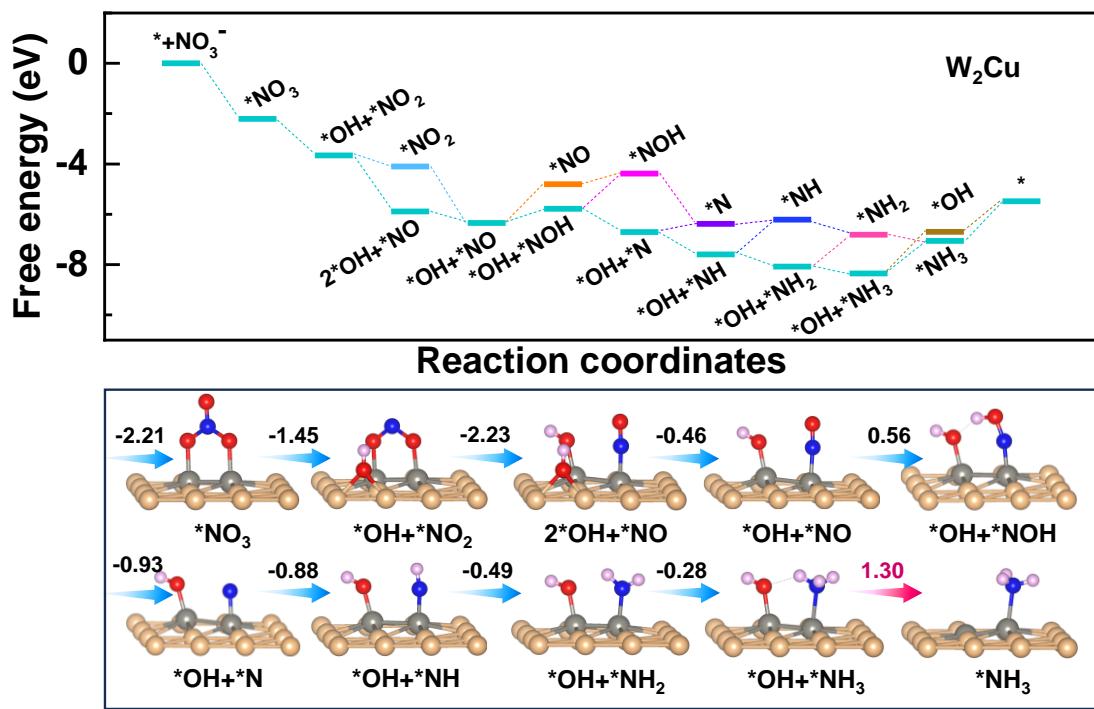


Fig. S16. Free energy diagram and the configurations of corresponding intermediates for the eNO₃RR on W₂Cu.

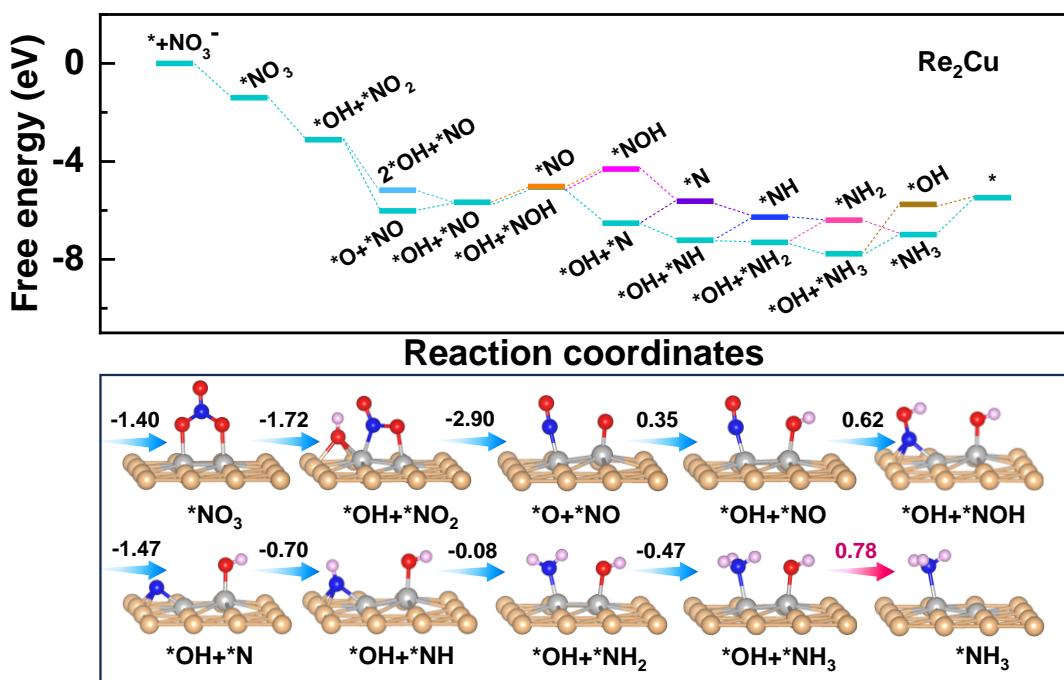


Fig. S17. Free energy diagram and the configurations of corresponding intermediates for the e NO_3 RR on Re_2Cu .

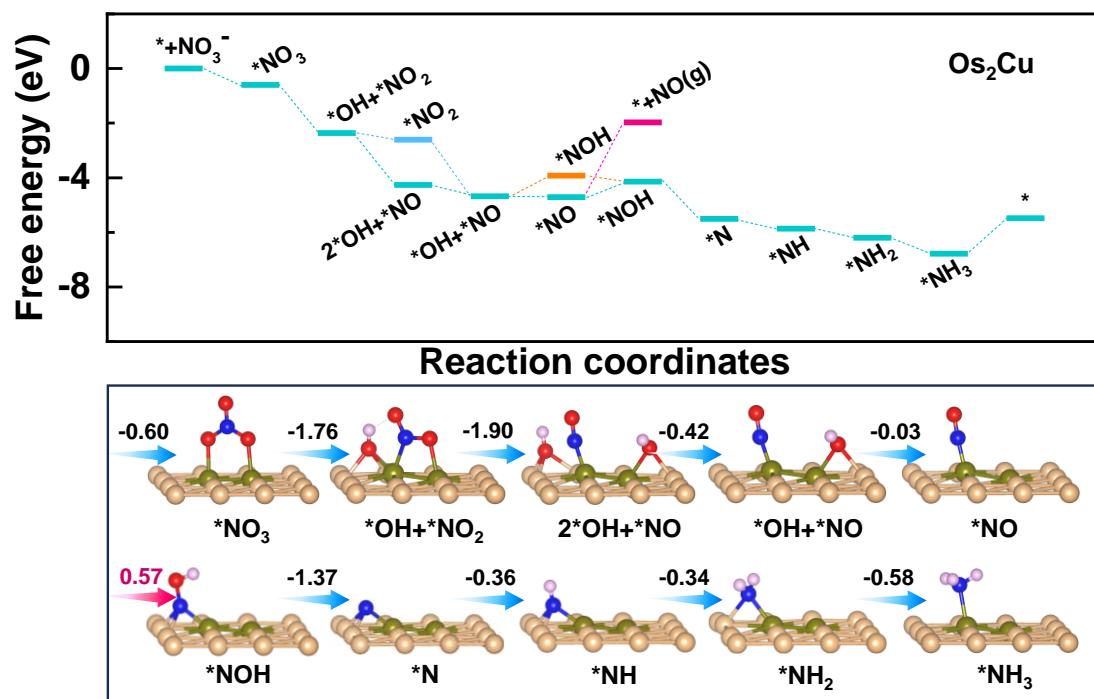


Fig. S18. Free energy diagram and the configurations of corresponding intermediates for the eNO_3RR on Os_2Cu .

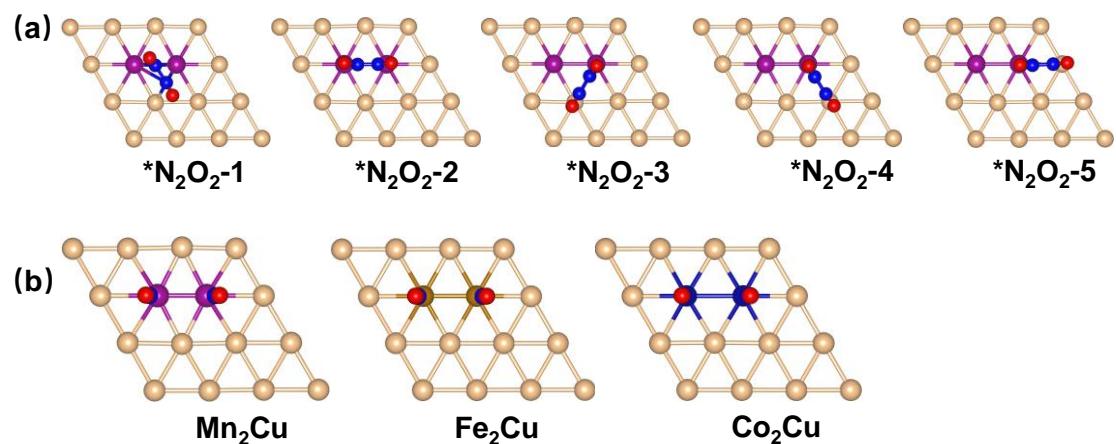


Fig. S19. (a) The considered adsorption sites and initial configurations of $*\text{N}_2\text{O}_2$ on TM_2Cu .
(b)The most stable adsorption configuration of $*\text{N}_2\text{O}_2$ on Mn_2Cu , Fe_2Cu and Co_2Cu .

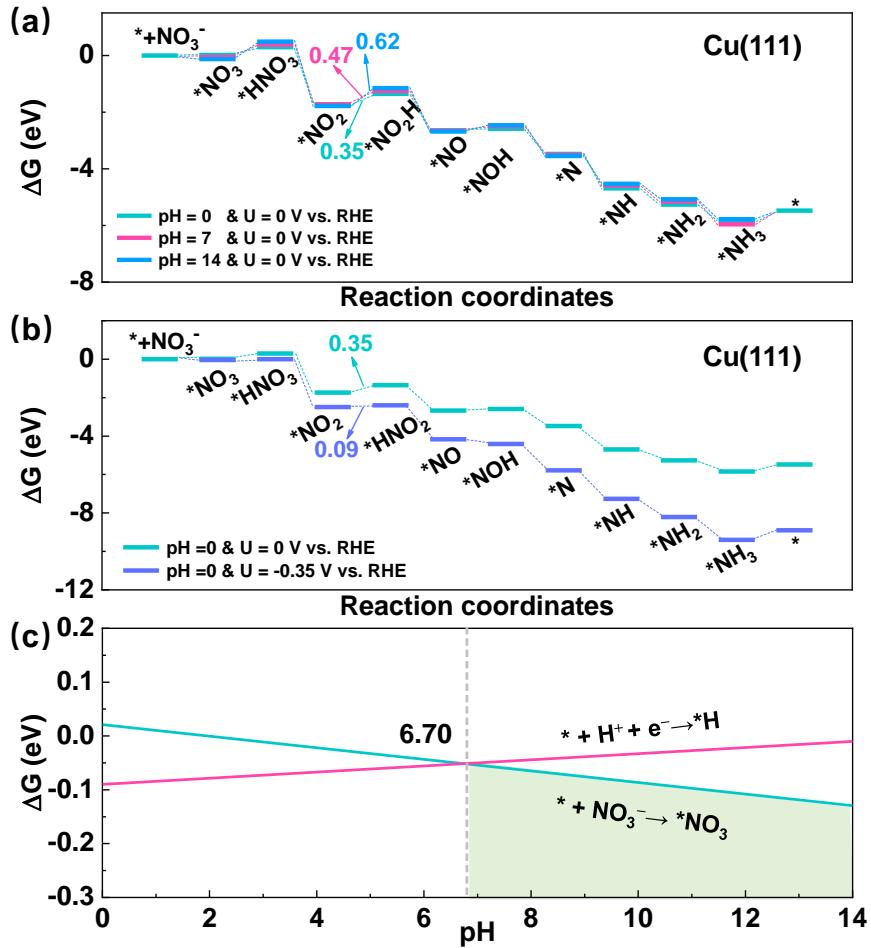


Fig. S20. (a) eNO₃RR free energy diagram along the optimal reaction path at different pH conditions for Cu(111). (b) eNO₃RR free energy diagram along the optimal reaction path at applied potentials for Cu(111). (c) The competitive relationship of ΔG(*NO₃) and ΔG(*H) between eNO₃RR and HER in all pH region on Cu(111).

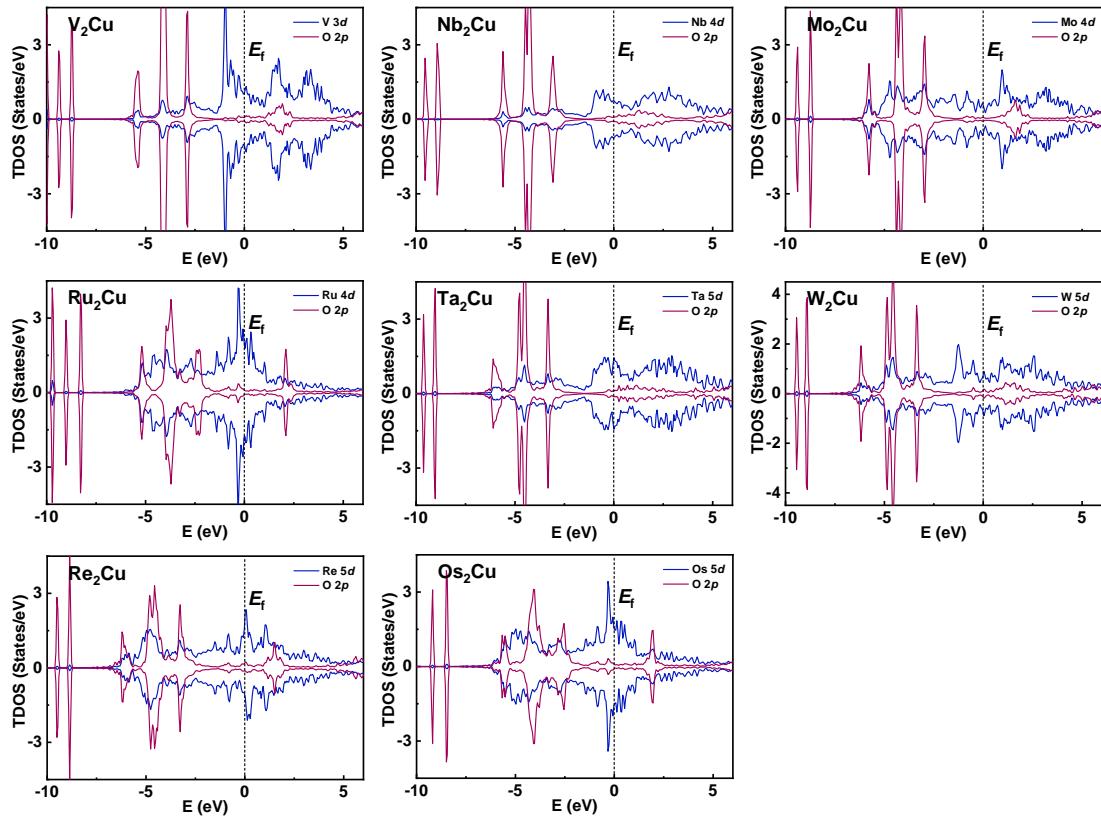


Fig. S21. Projected densities of states (PDOS) of the TM and O (in $^*\text{NO}_3$) $2p$ states, which is bonded with the TM atom. The vertical dashed line denotes the position of Fermi level (E_f).

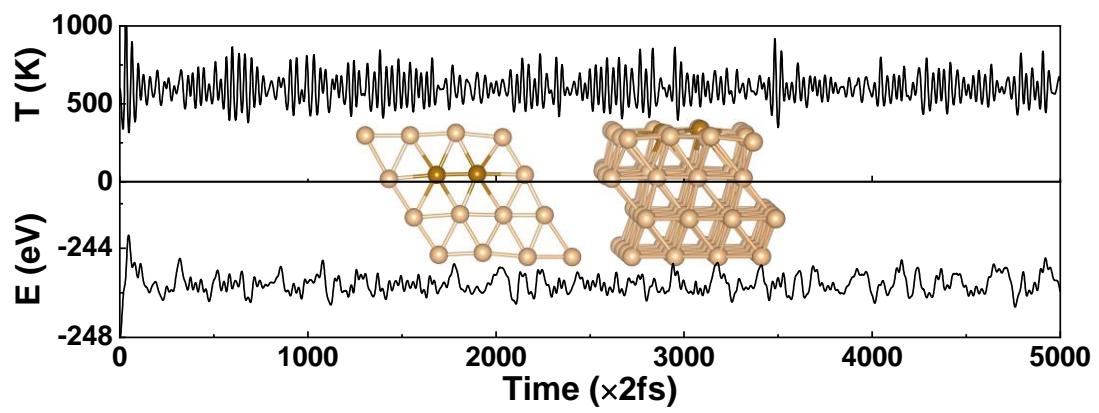


Fig. S22. The changes of temperature and energy during the AIMD simulation lasting 20 ps for Fe_2Cu , the top and side view of final configurations for the AIMD simulation are displayed.